



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

HAGIWARA, et al.

Application No.:

10/713,036

Filed:

November 17, 2003

For:

PHOTOSENSITIVE RESIN COMPOSITION

Expected

Group:

1752

Expected

Examiner:

J. Chu

SUPPLEMENTAL PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

February 26, 2004

Sir:

Supplementing the Preliminary Amendment filed November 17, 2003, please amend the above-identified application, prior to examination thereof, as listed in the following, and as set forth on the following pages:

Amendments to the Claims; and

Remarks are including following the amendments.